



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

August 21, 2026	
IGI Report Number	LG825627938
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	OVAL MODIFIED BRILLIANT
Measurements	8.04 X 5.76 X 3.87 MM

GRADING RESULTS

Carat Weight	1.43 CARAT
Color Grade	FANCY YELLOW
Clarity Grade	VS 1

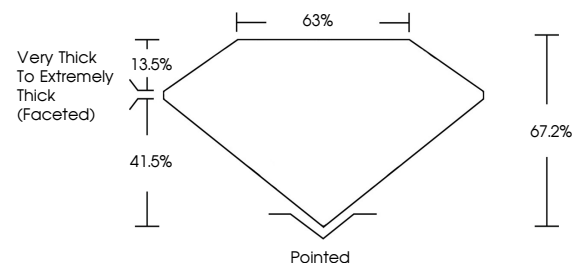
ADDITIONAL GRADING INFORMATION

Polish	VERY GOOD
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	131 LG825627938

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.

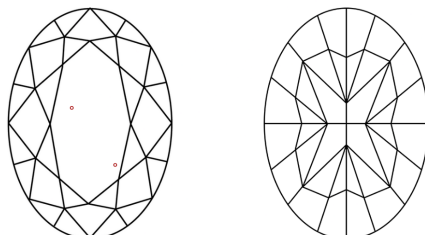
LG825627938
Report verification at iqi.org

PROPORTIONS



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

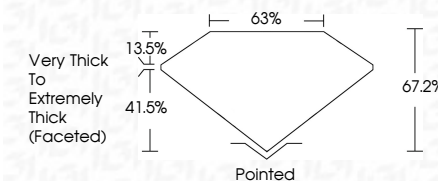
FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included



August 21, 2026	
IGI Report Number	LG825627938
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	OVAL MODIFIED BRILLIANT
Measurements	8.04 X 5.76 X 3.87 MM

GRADING RESULTS

Carat Weight	1.43 CARAT
Color Grade	FANCY YELLOW
Clarity Grade	VS 1



ADDITIONAL GRADING INFORMATION

Polish	VERY GOOD
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(16) LG825627938

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK, BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES

www.igi.org

August 21, 2026
 CGI Report No LG825627938
 CIVIL MODIFIED BILLANT

1.48 CARAT	
FANCY YELLOW	
VS 1	67.2%
	65%
Very Thick to Extremely Thick (included)	
Pointed	VERY GOOD
	EXCELLENT
	NONE
See GCSP0907038	

Comments:
This Laboratory Grown Diamond was
created by Chemical Vapor Deposition